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**Park**

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(54) **SEMICONDUCTOR PACKAGE INCLUDING SHEILDING COVER THAT COVERS MOLDED BODY**

23/3128; H01L 23/49838; H01L 24/48;  
H01L 25/0657; H01L 25/105; H01L  
25/50; H01L 2225/1058

(71) Applicant: **SAMSUNG ELECTRONICS CO., LTD.**, Suwon-si (KR)

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See application file for complete search history.

(72) Inventor: **Young-Woo Park**, Cheonan-si (KR)

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(73) Assignee: **Samsung Electronics Co., Ltd.** (KR)

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(\*) Notice: Subject to any disclaimer, the term of this patent is extended or adjusted under 35 U.S.C. 154(b) by 464 days.

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*Primary Examiner* — Jami Valentine Miller

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(74) *Attorney, Agent, or Firm* — Fish & Richardson P.C.

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(57) **ABSTRACT**

(52) **U.S. Cl.**

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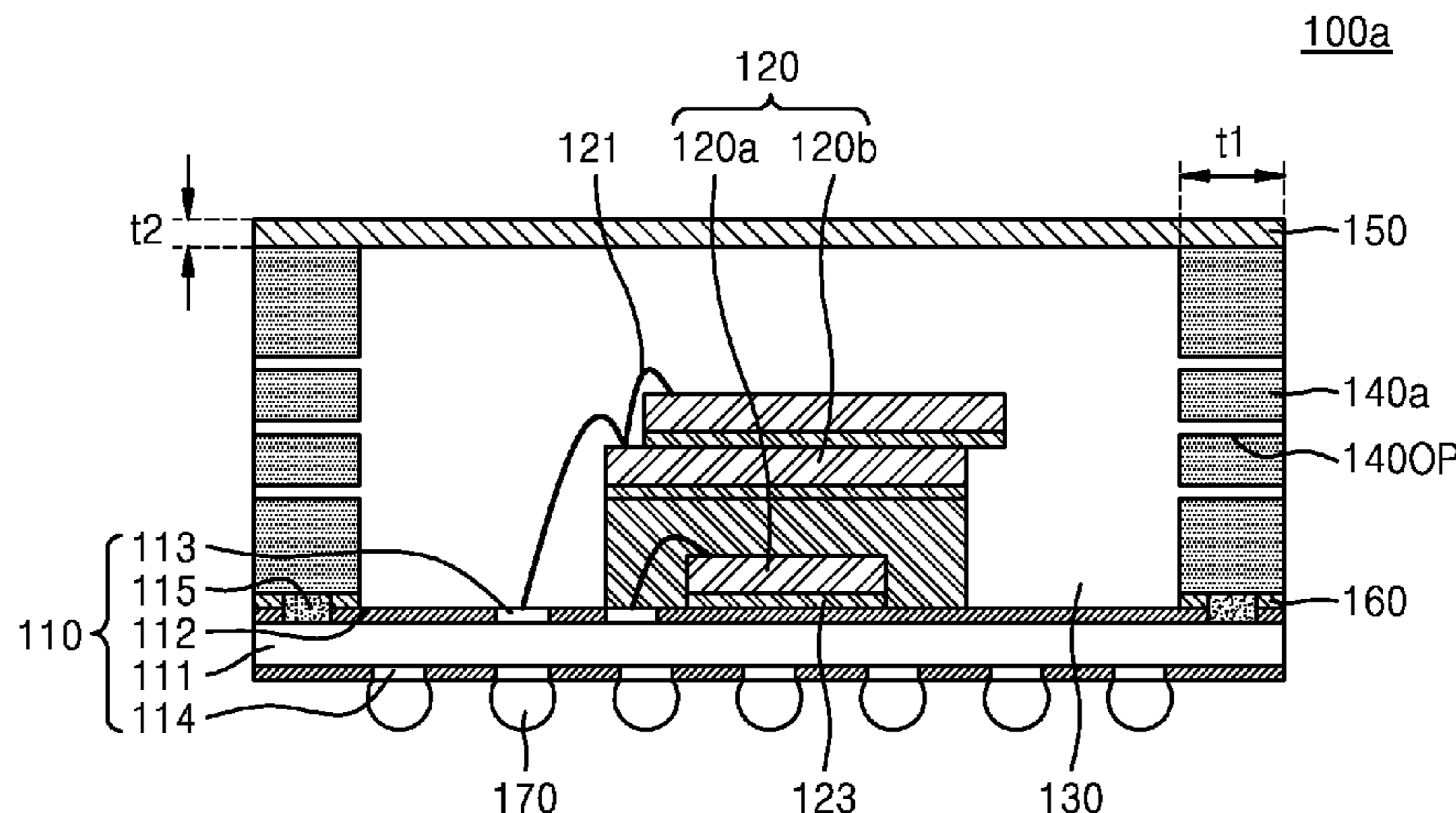
A method of fabricating a semiconductor package includes mounting at least one semiconductor chip to a package substrate, forming a shielding wall around the at least one semiconductor chip, forming a molded body on the package substrate in a space surrounded by the shielding wall, and forming a shielding cover covering the molding unit and in contact with the shielding wall.

(Continued)

(58) **Field of Classification Search**

**15 Claims, 11 Drawing Sheets**

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|      | <i>H01L 25/10</i>  | (2006.01) |                  |         |                        |

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FIG. 1

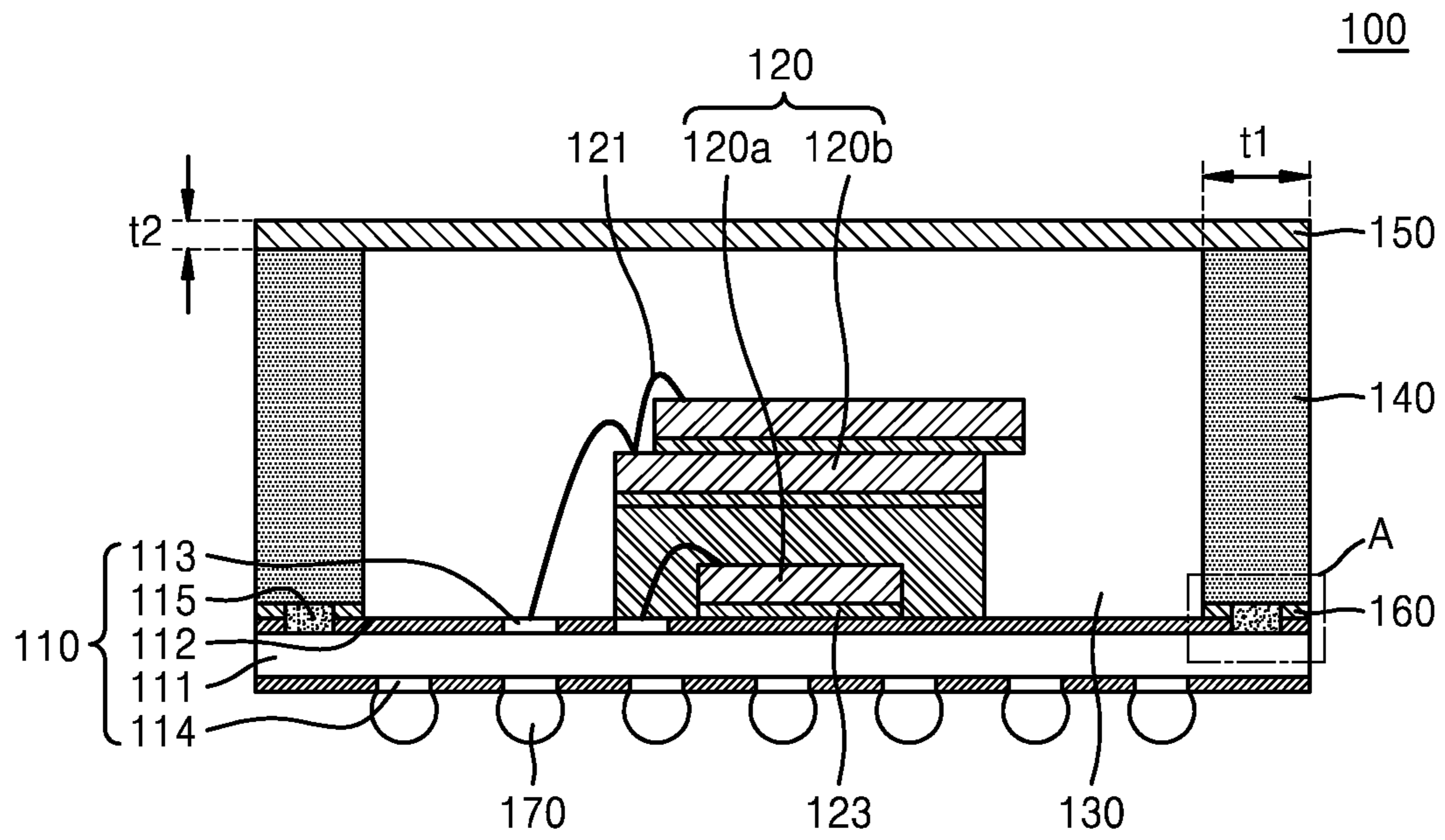


FIG. 2

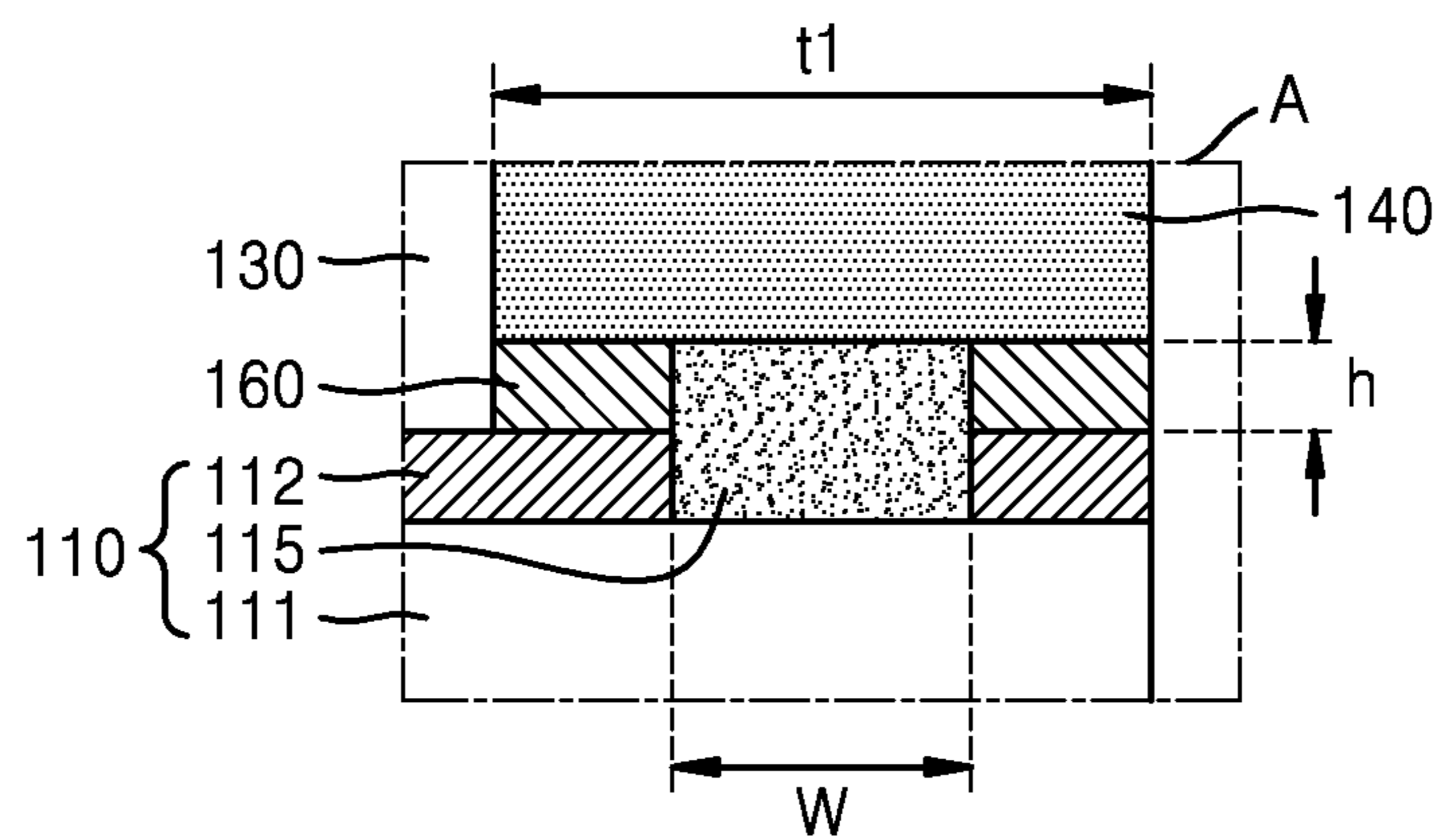


FIG. 3A

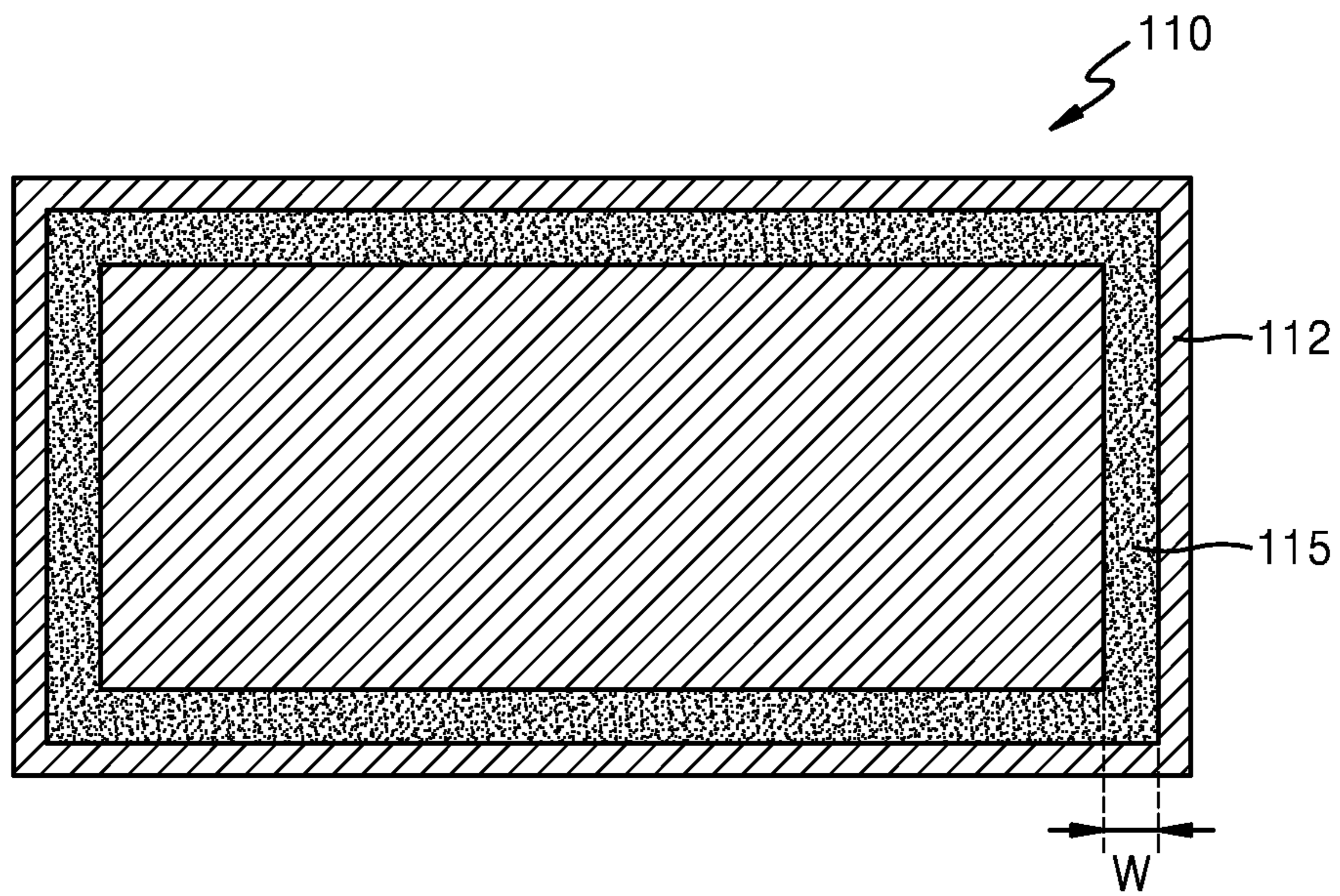


FIG. 3B

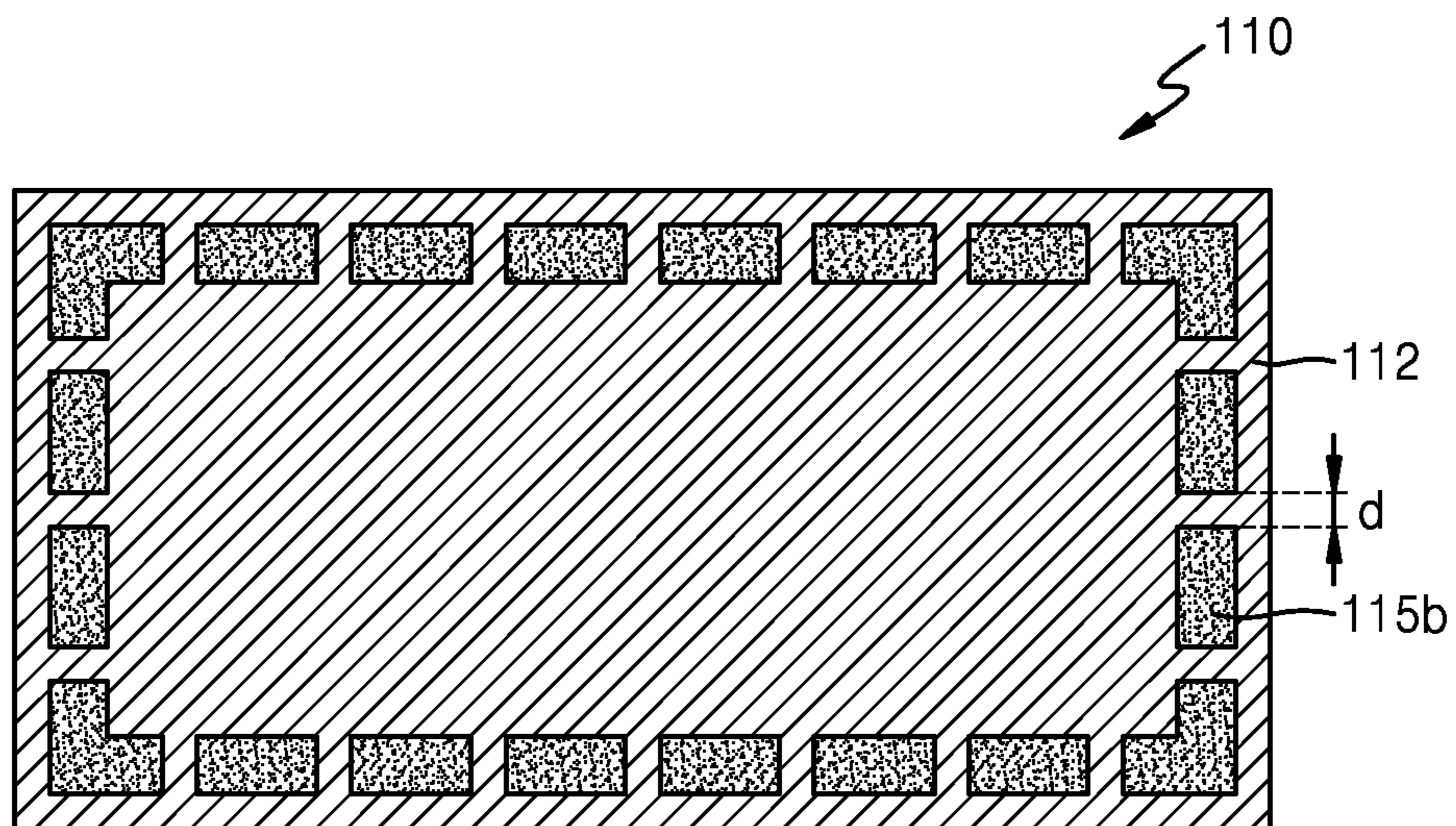


FIG. 3C

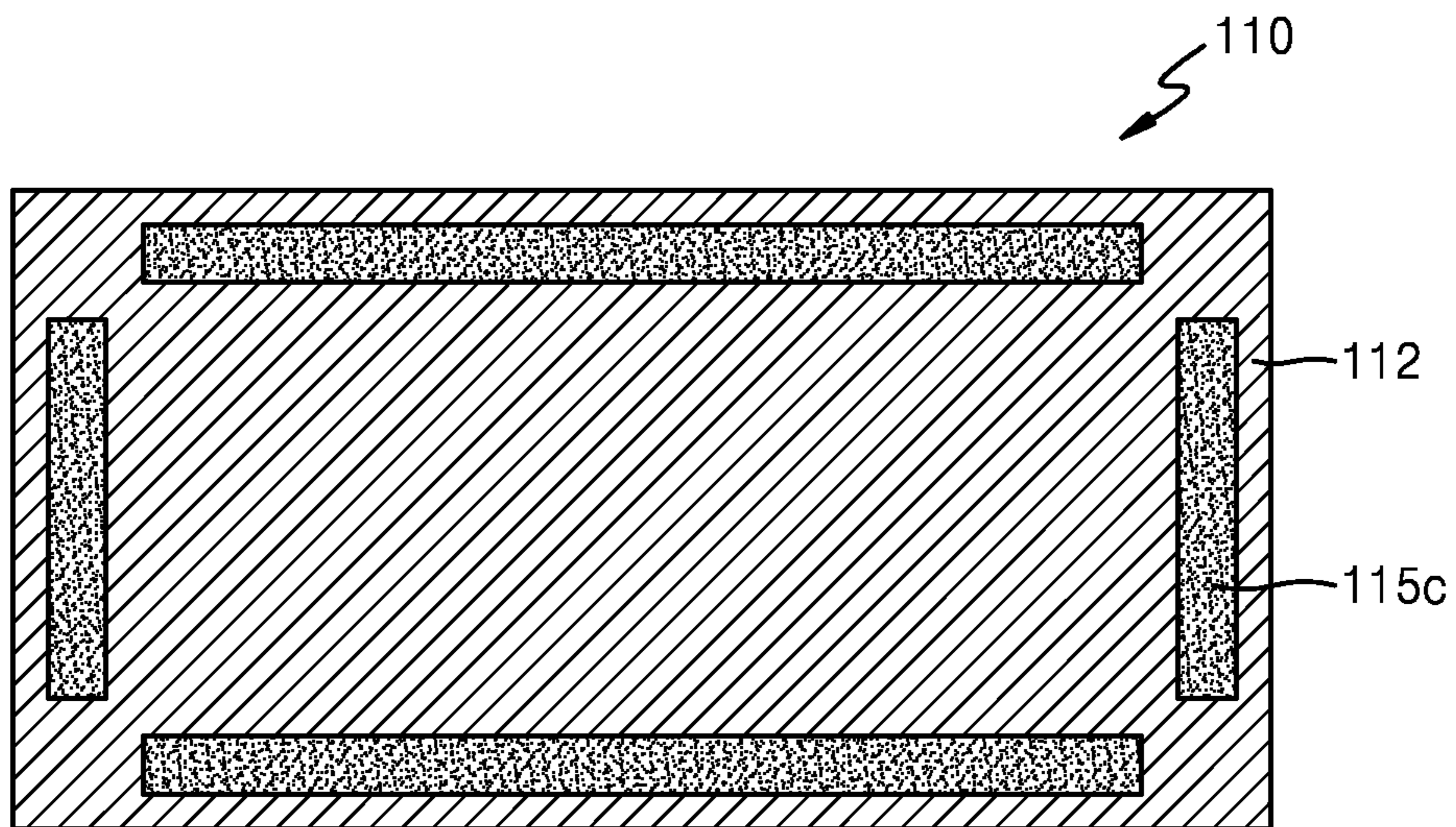


FIG. 4

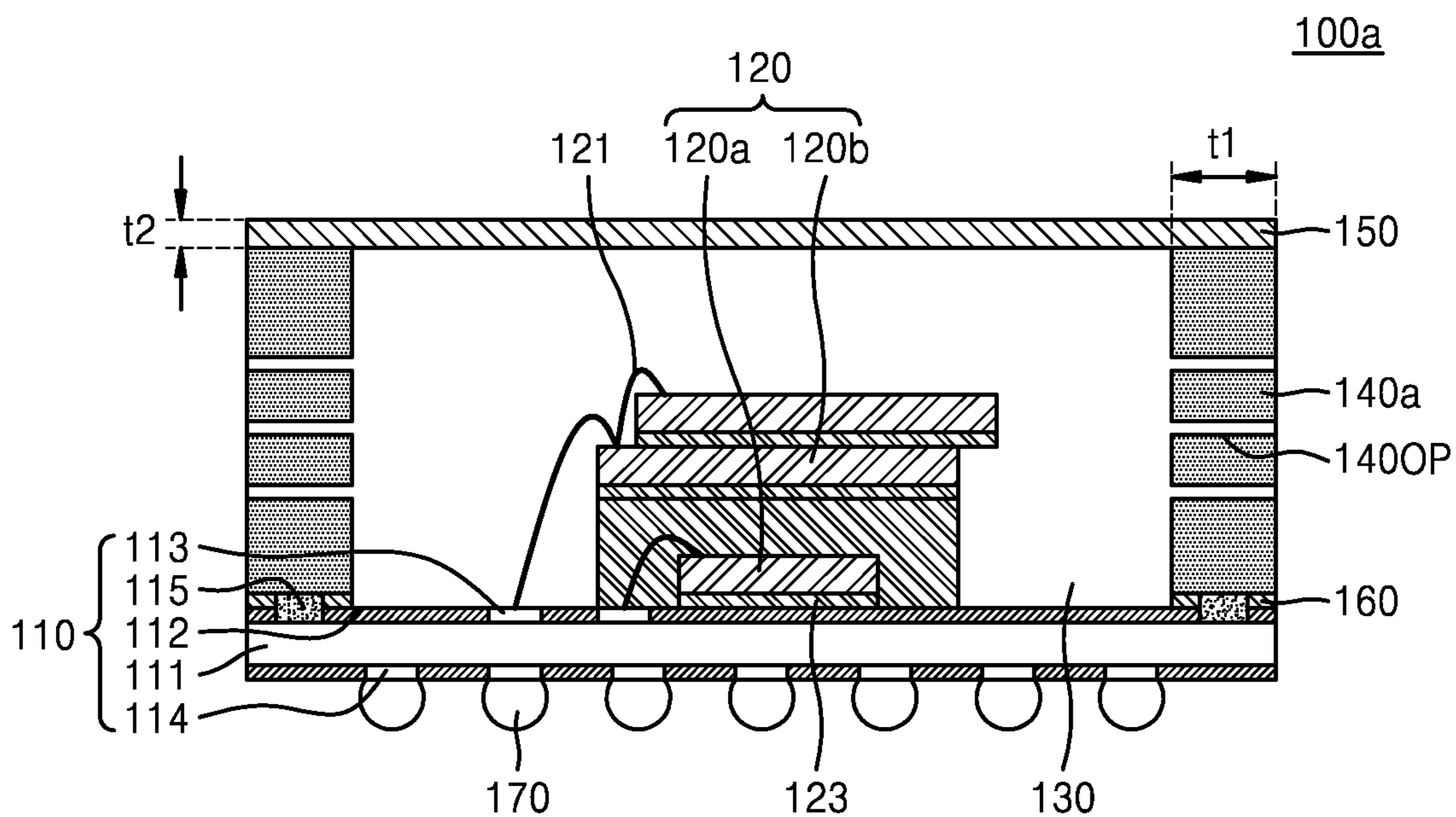


FIG. 5

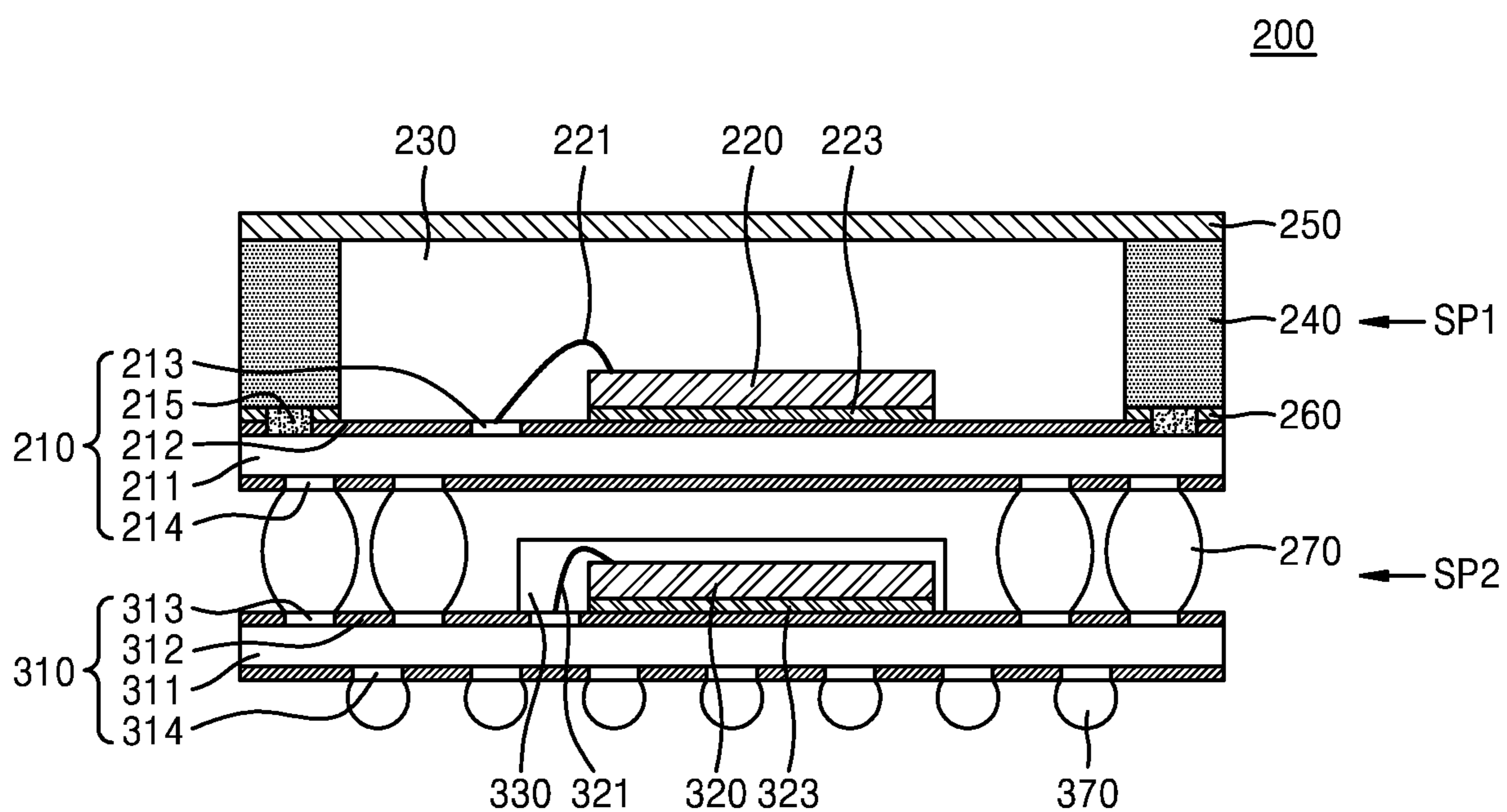


FIG. 6

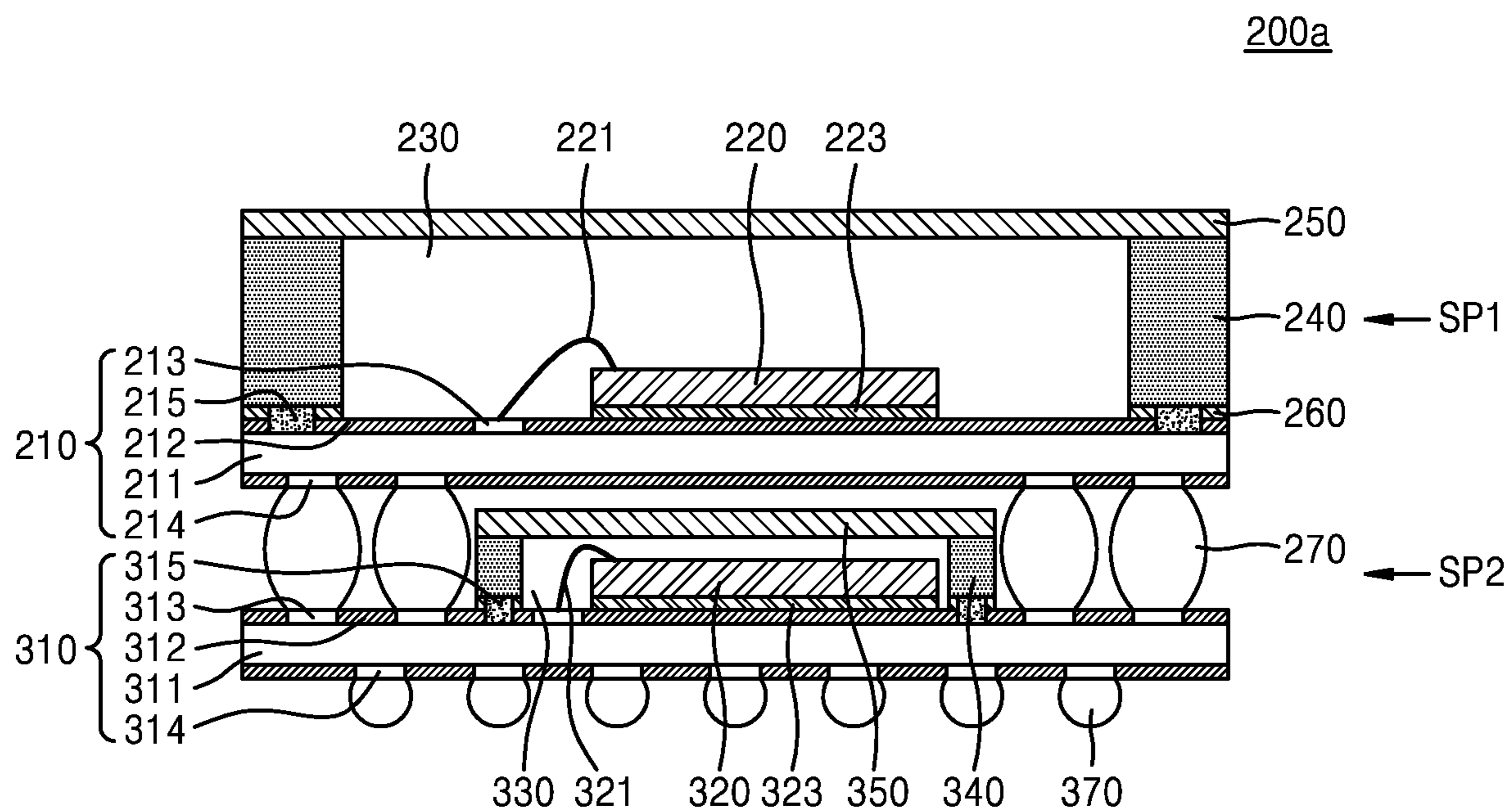


FIG. 7

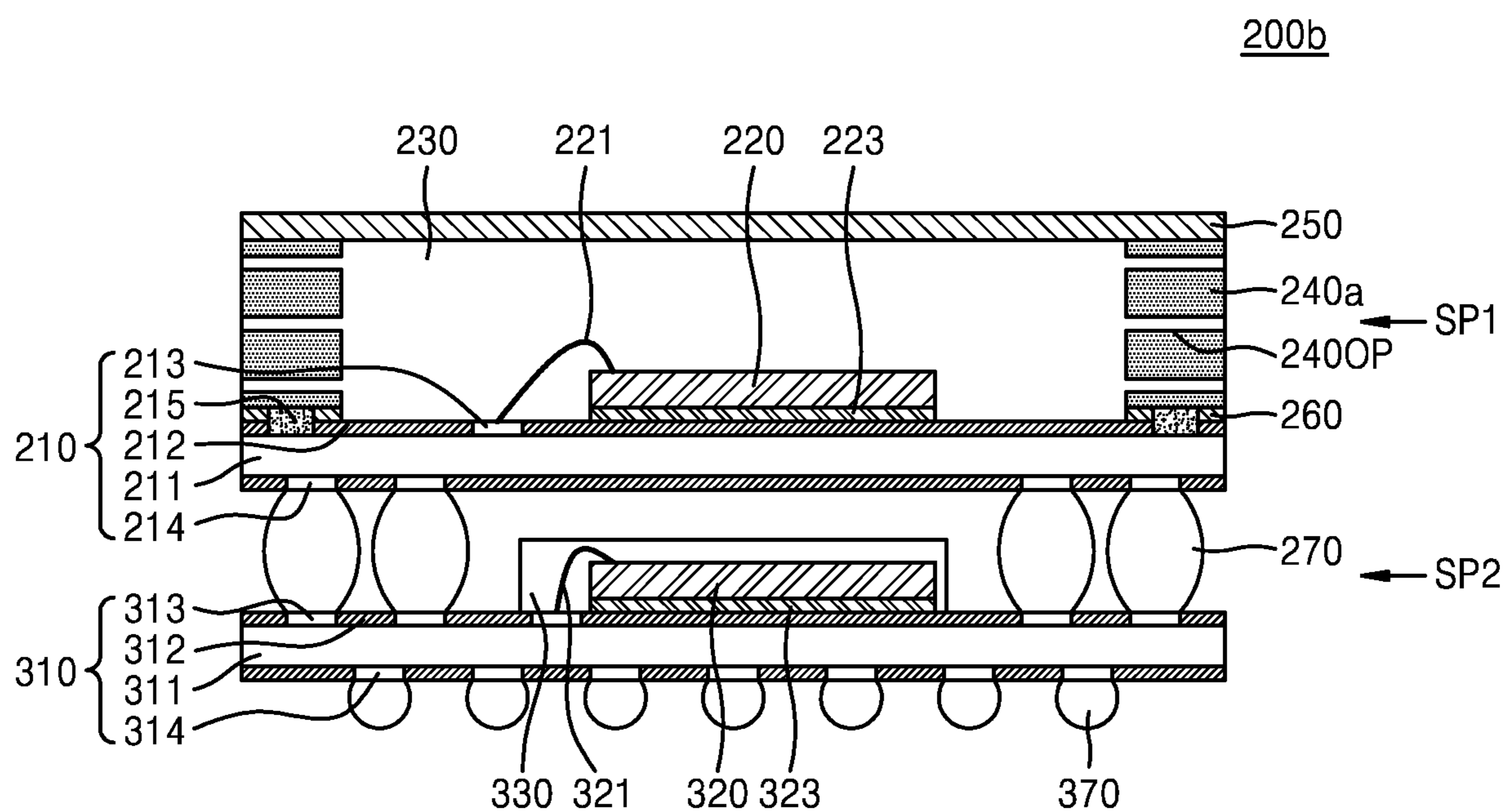


FIG. 8A

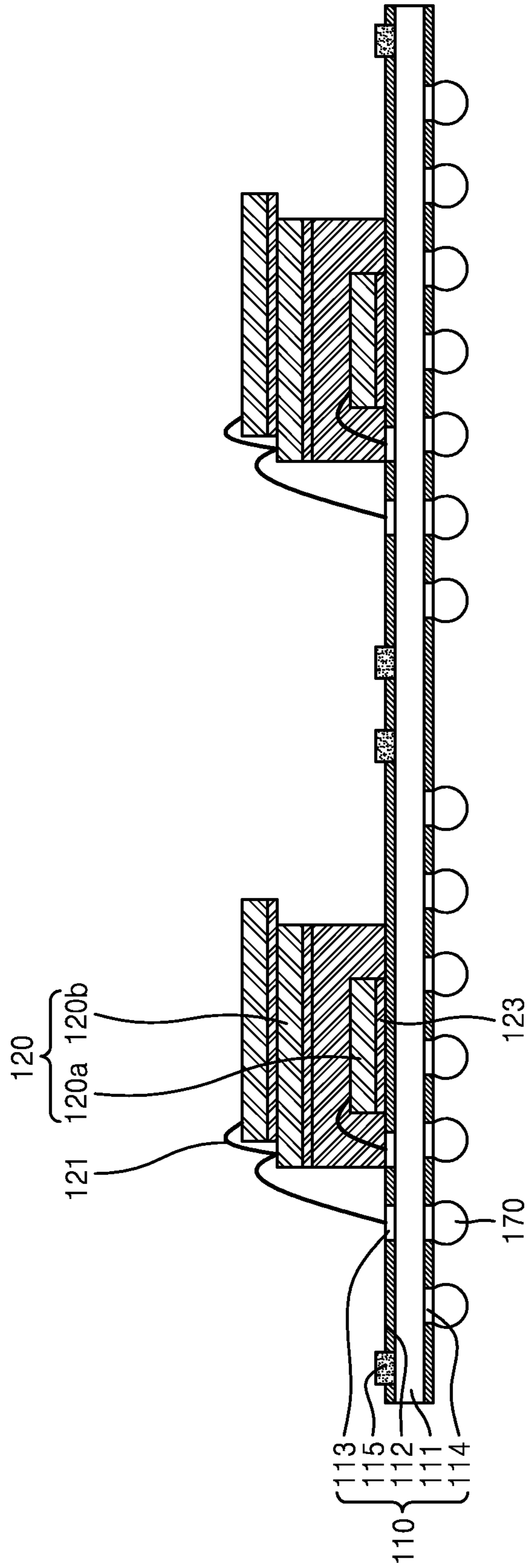




FIG. 8B

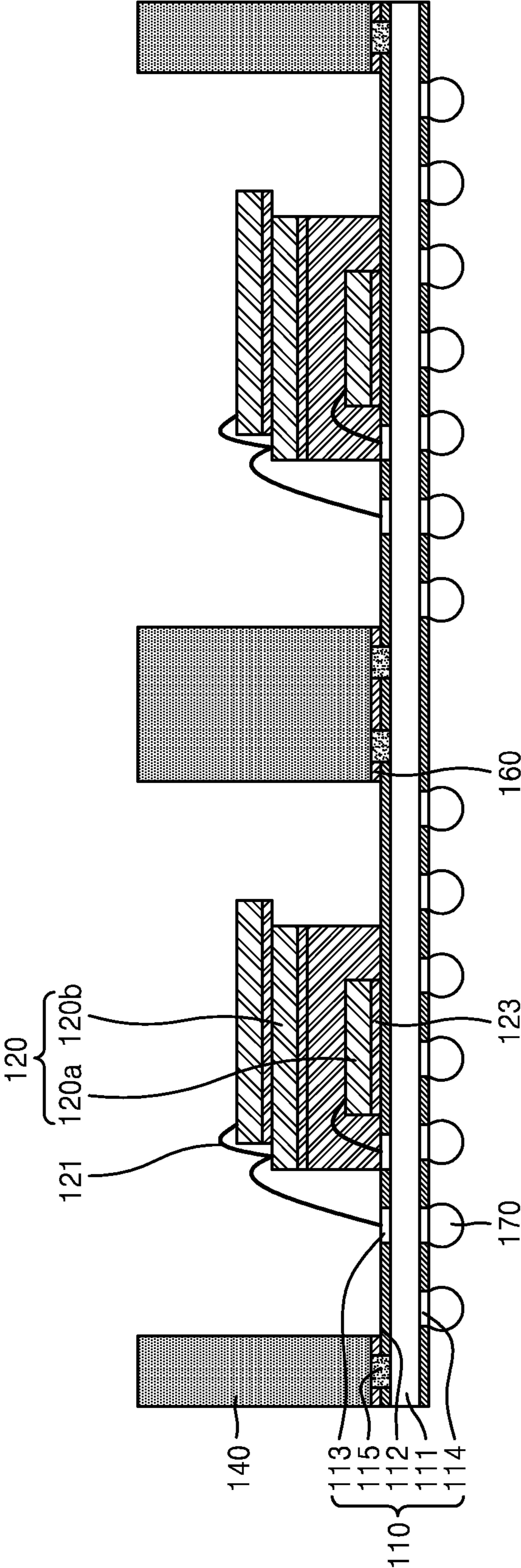


FIG. 8C

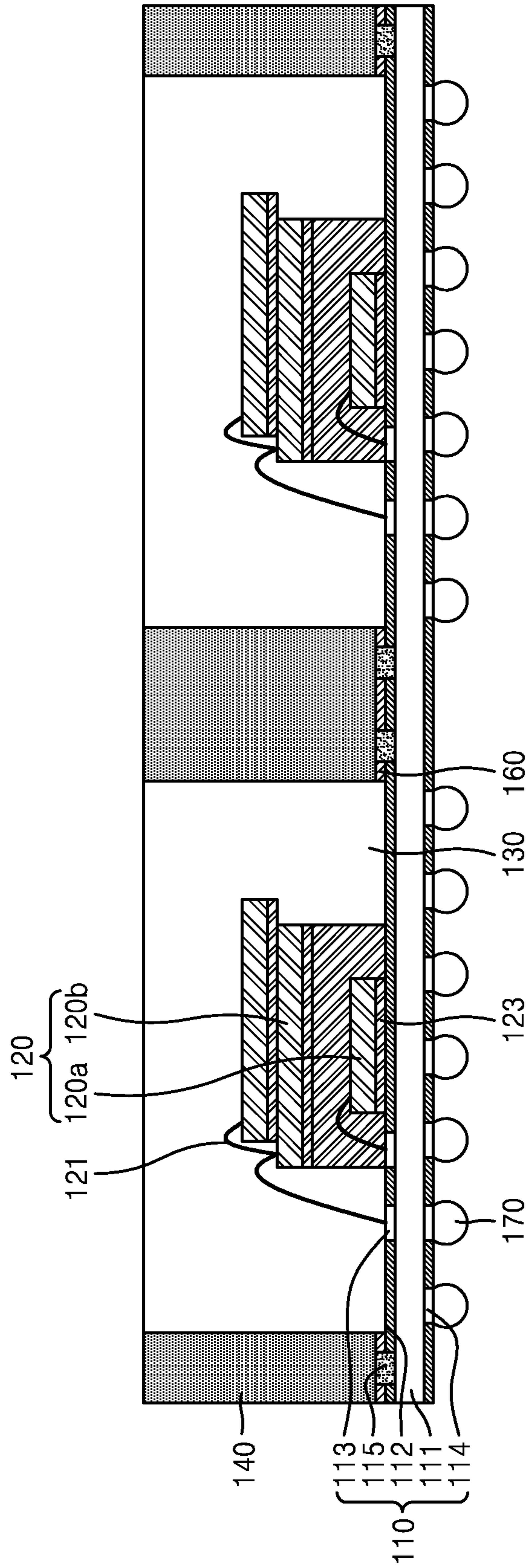


FIG. 8D

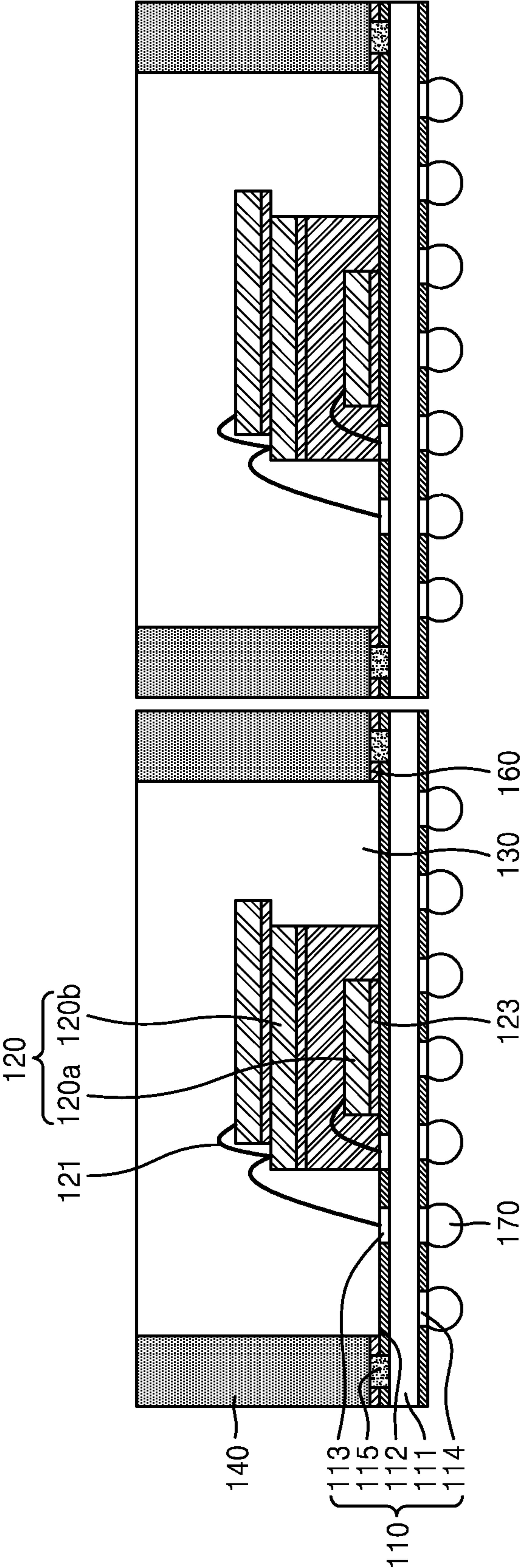


FIG. 9

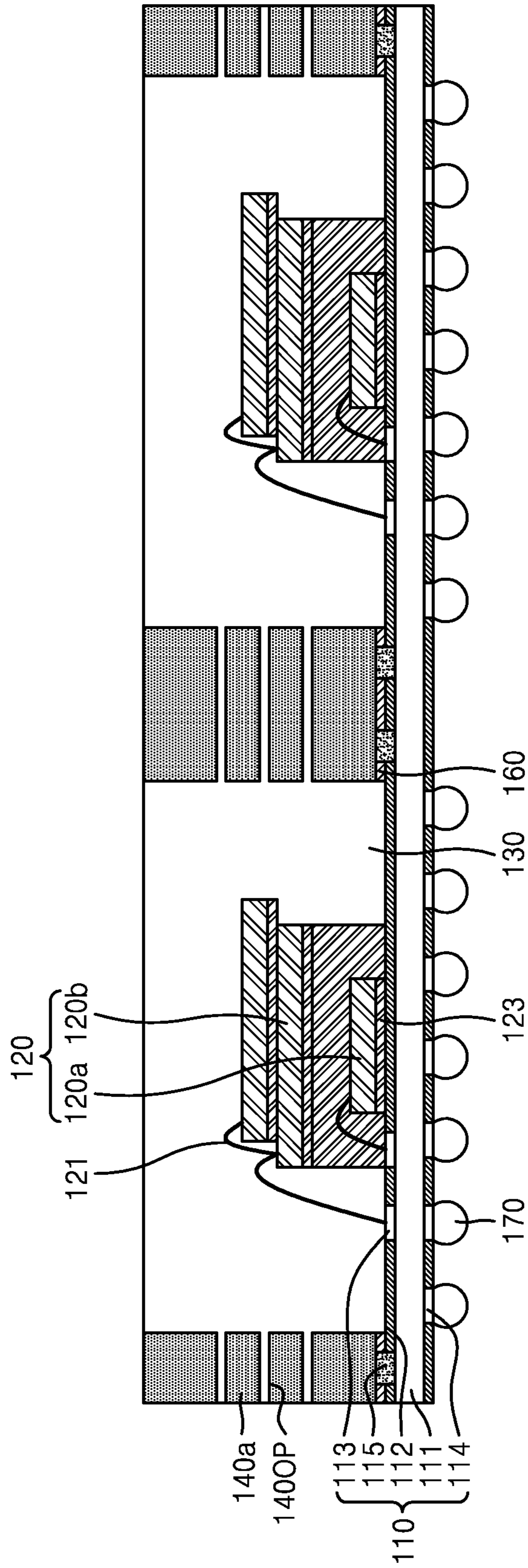
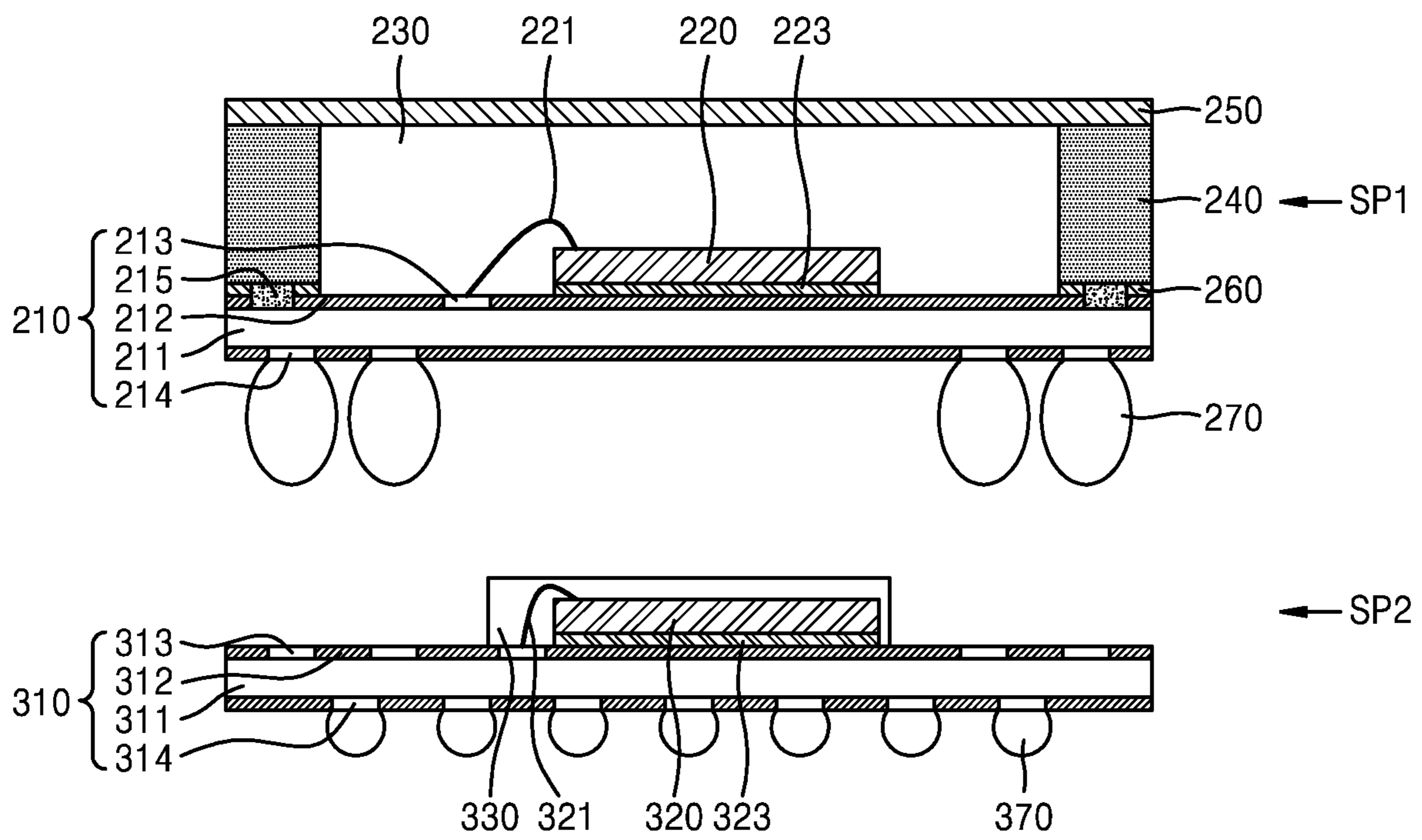


FIG. 10



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**SEMICONDUCTOR PACKAGE INCLUDING  
SHIELDING COVER THAT COVERS  
MOLDED BODY**

PRIORITY STATEMENT

This is a Continuation of U.S. application Ser. No. 16/224,556, filed Dec. 18, 2018, and a claim of priority is made to Korean Patent Application No. 10-2018-0073589, filed on Jun. 26, 2018, in the Korean Intellectual Property Office, the disclosures of which are hereby incorporated by reference in their entireties.

BACKGROUND

The inventive concept relates to a semiconductor package and to a method of fabricating a semiconductor package.

A semiconductor chip of a semiconductor package may operate abnormally due to electromagnetic interference (EMI). Electromagnetic interference (EMI) in this context refers to a phenomenon in which an electronic device external but adjacent to the package generates an electric field which is superimposed on and hence, alters the operation, of the chip of the package. Electromagnetic interference shielding has been created to ameliorate the affect of EMI. Such electromagnetic interference shielding in a semiconductor package is becoming more important as the distance between semiconductor packages is becoming smaller in accordance with the demand for smaller electronic product. An electromagnetic interference shielding structure of a semiconductor package has been fabricated by an electroplating or a physical vapor deposition (PVD).

SUMMARY

According to an aspect of the inventive concept, there is provided a method of fabricating a semiconductor package, the method including: mounting at least one semiconductor chip to an upper surface of a package substrate, forming a shielding wall that extends around sides of the at least one semiconductor chip above the package substrate, forming a molded body in a space delimited by the shielding wall and the package substrate, and forming a shielding cover that covers the molded body and contacts the shielding wall.

According to another aspect of the inventive concept, there is provided a method of fabricating a semiconductor package, the method including: providing a package substrate comprising a base having an upper surface, a solder resist layer on the upper surface of the base and a protrusion contacting the base and extending into the solder resist layer, mounting at least one semiconductor chip to the package substrate atop the upper surface of the base, attaching to the package substrate a shielding wall that extends over the protrusion and circumferentially around the at least one semiconductor chip, forming a molded body in a space delimited by the shielding wall and the package substrate, and forming a shielding cover covering the molded body and in contact with the shielding wall.

According to another aspect of the inventive concept, there is provided a method of fabricating a semiconductor package, the method including: mounting semiconductor chips on an upper surface of a package substrate in a horizontal array in which respective chips of the array are spaced laterally from each other in a direction parallel to the upper surface of the package substrate, forming a shielding wall extending around each of the semiconductor chips above the package substrate, depositing molding material in

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spaces delimited by the shielding wall and the package substrate, curing or allowing the molding material to cure to thereby form molded bodies that encapsulate the semiconductor chips on the package substrate within the spaces, respectively, cutting through the shielding wall and the package substrate in regions between the semiconductor chips of the array, and forming a shielding cover that covers each of the molded bodies.

According to another aspect of the inventive concept, there is provided a method of fabricating a semiconductor package, the method including: forming a package substrate comprising a base of electrically insulating material, an upper pad of electrically conductive material at an upper surface of the base, and a protrusion of electrically conductive material extending upright on the upper surface of the base, disposing at least one semiconductor chip in a chip mounting region of the semiconductor package above the package substrate and electrically connecting the at least one semiconductor chip to the upper pad of the package substrate, forming an electromagnetic radiation shielding wall that delimits the chip mounting region with the upper surface of the package substrate by walling in the chip mounting region of the semiconductor package with a fence of electrically conductive material disposed in contact with the protrusion of the package substrate, depositing a molding compound in the chip mounting region delimited by the electromagnetic radiation shielding wall and the upper surface of the package substrate after the at least one semiconductor chip has been disposed in the chip mounting region and electrically connect to the upper pad of the package substrate, curing or allowing the molding compound to cure to thereby form a molded body that encapsulates the at least one semiconductor chip on the package substrate, and forming a cover of electrically conductive material, serving as an electromagnetic radiation cover shield, over the molded body as disposed in contact with the electromagnetic radiation shielding wall.

BRIEF DESCRIPTION OF THE DRAWINGS

The inventive concept will be more clearly understood from the following detailed description taken in conjunction with the accompanying drawings in which:

FIG. 1 is a cross-sectional view of an example of a semiconductor package according to the inventive concept;

FIG. 2 is an enlarged view of an area A of the semiconductor package of FIG. 1;

FIG. 3A is a plan view of a protruding unit of a package substrate;

FIG. 3B is a plan view of a protruding unit of a package substrate;

FIG. 3C is a plan view of a protruding unit of a package substrate;

FIG. 4 is a cross-sectional view of another example of a semiconductor package according to the inventive concept;

FIG. 5 is a cross-sectional view of another example of a semiconductor package according to the inventive concept;

FIG. 6 is a cross-sectional view of another example of a semiconductor package according to the inventive concept;

FIG. 7 is a cross-sectional view of another example of a semiconductor package according to the inventive concept;

FIGS. 8A, 8B, 8C and 8D are cross-sectional views of a semiconductor package during the course of its manufacture and together illustrate an example of a method of fabricating a semiconductor package according to the inventive concept;

FIG. 9 is a cross-sectional view of an intermediate product in a phase of an example of a method of mass producing semiconductor packages according to the inventive concept; and

FIG. 10 is a cross-sectional view of a semiconductor package during the course of its manufacture illustrating an example of a method of fabricating a semiconductor package according to the inventive concept.

#### DETAILED DESCRIPTION

Examples of semiconductor packages and methods of fabricating the same, according to the inventive concept, will now be described in more detail with respect to the drawings. Note, a single element or feature may be referred to in the following description for the sake of convenience although a semiconductor package according to the inventive concept may have a plurality of such elements or features as shown in the drawings.

FIG. 1 is a cross-sectional view of a semiconductor package 100 according to the inventive concept. FIG. 2 is an enlarged view of an area A of the semiconductor package 100 shown in FIG. 1.

Referring to FIG. 1 and FIG. 2 together, the semiconductor package 100 may include a package substrate 110, an external connecting unit 170, at least one semiconductor chip 120, a molding unit 130, a shielding wall 140, and a shielding cover 150.

The package substrate 110 may be, for example, a printed circuit board (PCB). The package substrate 110 may include at least one base layer 111 of electrically insulating material (which layer or layers may be referred to simply as the “base” of the package substrate), a solder resist layer 112, an upper pad 113, a lower pad 114, and a protruding unit 115. The base layer 111 may be formed of an epoxy resin, a polyester resin, a polyimide resin, or a combination thereof. The base layer 111 may be formed of, for example, a glass fiber epoxy composite material. The solder resist layer 112 may cover an upper surface and a lower surface of the base layer 111. The upper pad 113 may be positioned at and more specifically, above the upper surface of the base layer 111 and may not be covered by the solder resist layer 112. The lower pad 114 may be positioned at and more specifically on the lower surface of the base layer 111 and may not be covered by the solder resist layer 112. The upper pad 113 and the lower pad 114 comprise a conductive material such as copper (Cu). The upper pad 113 and the lower pad 114 may be connected to each other through an interconnection (not shown) in the base layer 111. The protruding unit 115 may extend from the base layer 111 to a lower end surface of the shielding wall 140. That is, one end of the protruding unit 115 may be in contact with the base layer 111, and the other end of the protruding unit 115 may be in contact with the lower end surface of the shielding wall 140. The protruding unit 115 may comprise a conductive material such as copper (Cu). The protruding unit 115 may be positioned adjacent to an edge of the package substrate 110. The protruding unit 115 has a width W in a direction parallel to the package substrate 110. In addition, the protruding unit 115 protrudes from the solder resist layer 112 by a distance h.

The external connecting unit 170 may be arranged on the lower pad 114 of the package substrate 110. The external connecting unit 170 may comprise gold (Au), copper (Cu), nickel (Ni), tin (Sn), lead (Pb), or a combination thereof. The external connecting unit 170 may comprise a plurality of terminals, e.g., solder balls.

The semiconductor chip 120 may be a logic chip or a memory chip. In the case of the former, the logic chip may be, for example, a memory controller chip, a central processing unit (CPU) chip, a graphics processing unit (GPU) chip, or an application processor (AP) chip. In the case of the latter, the memory chip may be, for example, a dynamic random access memory (DRAM) chip, a static random access memory (SRAM) chip, a flash memory chip, an electrically erasable and programmable read-only memory (EEPROM) chip, a phase-change random access memory (PRAM) chip, a magnetic random access memory (MRAM) chip, or a resistive random access memory (RRAM) chip. In any case, the semiconductor chip 120 may be attached to an upper surface of the package substrate 110, within a “chip mounting region” of the package, by a chip adhesive layer 123. The semiconductor chip 120 may be electrically connected to the package substrate 110 by a bonding wire 121. In other examples, the semiconductor chip 120 is connected to the package substrate 110 by a conductive bump. The semiconductor chip 120 may be spaced apart from the shielding wall 140 and the shielding cover 150.

In some examples, the at least one semiconductor chip 120 may include a first semiconductor chip 120a and a plurality of second semiconductor chips 120b. The first semiconductor chip 120a and the second semiconductor chip 120b may be of different types. For example, the first semiconductor chip 120a may be a logic chip and the second semiconductor chip 120b may be a memory chip. However, the numbers and types of semiconductor chips of the semiconductor package 100 are not limited to those shown in the figures and/or described above.

The molding unit 130 may cover the upper surface of the package substrate 110 and encapsulate the at least one semiconductor chip 120 in the chip mounting region atop the package substrate 110. The molding unit 130 may be formed of a thermosetting resin, a thermoplastic resin, a UV curable resin, or a combination thereof. The molding unit 130 may comprise, for example, an epoxy resin, a silicone resin, or a combination thereof. The molding unit 130 may be formed of, for example, an epoxy mold compound (EMC).

The shielding wall 140 may extend circumferentially around the molding unit 130. Thus, the shielding wall may fence in the chip mounting region within which the at least one chip 120 is mounted to the package substrate. One end of the shielding wall 140 may contact the protruding unit 115 of the package substrate 110 and the other end of the shielding wall 140 may be in contact with the shielding cover 150. The shielding wall 140 is formed of conductive material such as copper (Cu) nickel (Ni), silver (Ag), gold (Au) iron (Fe), or a combination thereof. The shielding wall 140 may have a first thickness t1 in a direction parallel to an upper surface of the package substrate 110, namely, the upper surface of the base layer 11 of the package substrate 110. The first thickness t1 of the shielding wall 140 may be, for example, about 10  $\mu\text{m}$  to 500  $\mu\text{m}$ . The shielding wall 140 may be grounded through the protruding unit 115 of the package substrate 110. The first thickness t1 of the shielding wall 140 may be greater than the width W of the protruding unit 115, i.e., the aforementioned dimension of the protruding unit 115 in the direction parallel to the package substrate 110. In addition, the first thickness t1 of the shielding wall 140 may be greater than the height h of the protruding unit 115, i.e., the aforementioned distance from the solder resist layer 112 to an upper surface of the protruding unit 115 in a direction perpendicular to the upper surface of the package substrate 110.

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In some examples, the shielding wall **140** is attached to the package substrate **110** by a shielding wall adhesive layer **160**. The shielding wall adhesive layer **160** may be interposed between the upper surface of the solder resist layer **112** of the package substrate **110** and the shielding wall **140**. The protruding unit **115** of the package substrate **110** may extend through the shielding wall adhesive layer **160**. The shielding wall adhesive layer **160** may be, for example, an epoxy resin.

The shielding cover **150** may cover an upper surface of the molding unit **130** and be in contact with the shielding wall **140**. The shielding cover **150** may be formed of conductive material such as copper (Cu), nickel (Ni), silver (Ag), gold (Au), iron (Fe), or a combination thereof. In some examples, the shielding cover **150** is an electromagnetic radiation absorbing tape. In some examples, the shielding cover **150** is of a different material from the shielding wall **140**. For example, the shielding wall **140** may include copper (Cu) and the shielding cover **150** may be an electromagnetic radiation absorbing tape. The shielding cover **150** may have a thickness  $t_2$  in the direction perpendicular to the package substrate **110**. In some examples, the thickness  $t_1$  of the shielding wall **140** is different from the thickness  $t_2$  of the shielding cover **150**. In particular, the thickness  $t_1$  of the shielding wall **140** may be greater than the thickness  $t_2$  of the shielding cover **150**. The shielding cover **150** may be grounded through the shielding wall **140** and the protruding unit **115** of the package substrate **110**.

FIG. 3A is a plan view of one version of the protruding unit **115** of the package substrate **110**.

Referring to FIG. 3A, the protruding unit **115** of the package substrate **110** may extend along a closed curve. In addition, the protruding unit **115** of the package substrate **110** may extend adjacent to, i.e., alongside, the perimeter of the package substrate **110**. In some examples, the package substrate **110** has an approximately rectangular shape. However, the shape of the protruding unit **115** is not limited to being rectangular.

FIG. 3B is a plan view of another version of the protruding unit **115b** of the package substrate **110**.

Referring to FIG. 3B, the protruding unit **115b** of the package substrate **110** may include a plurality of portions which are spaced apart from each other. A distance  $d$  between the plurality of portions of the protruding unit **115b** and the distance  $h$  (see FIG. 2) from the upper surface of the solder resist layer **112** to the upper surface of the protruding unit **115b** are small enough to allow the protruding unit **115b** to effect electromagnetic shielding. The plurality of portions of the protruding unit **115b** may be arranged along a closed curve. For example, the package substrate **110** may have an approximately rectangular shape and the plurality of portions of the protruding unit **115b** may be arranged along an approximately rectangular path corresponding to the shape of the perimeter of the package substrate **110**. However, the shape of the closed path along which the portions of the protruding unit **115b** are laid out is not limited to being rectangular.

FIG. 3C is a plan view of still another version of the protruding unit **115c** of the package substrate **110**.

Referring to FIG. 3C, the protruding unit **115c** of the package substrate **110** may include a plurality of portions respectively adjacent to edges of the package substrate **110**. In some examples, the package substrate **110** has an approximately rectangular shape with four edges and the protruding unit **115c** may have four portions respectively adjacent to four edges of the package substrate **110**.

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FIG. 4 is a cross-sectional view of another example of a semiconductor package **100a** according to the inventive concept. Hereinafter, mostly only differences between the semiconductor package **100** shown in FIG. 1 and the semiconductor package **100a** shown in FIG. 4 will be described.

Referring to FIG. 4, a shielding wall **140a** may have at least one opening **1400P** extending radially therethrough. The opening **1400P** may be a hole or a slit. The opening **1400P** is small enough to allow the shielding wall **140a** to still effect an electromagnetic shielding of the at least one semiconductor package **120**. The opening **1400P** may have any shape (cross section). When a space surrounded by the shielding wall **140a** is filled with molding compound (described later), the opening **1400P** may allow excess molding material to pass through the shielding wall **140a**.

FIG. 5 is a cross-sectional view of still another example of a semiconductor package **200** according to the inventive concept.

Referring to FIG. 5, the semiconductor package **200** may include a first sub-package **SP1**, a second sub-package **SP2**, and a plurality of inter-package connecting units **270**. That is, the semiconductor package **200** may be a package on package (POP) semiconductor device.

The first sub-package **SP1** may include a first package substrate **210**, a first semiconductor chip **220**, a first molding unit **230**, a first shielding wall **240**, and a first shielding cover **250**.

The first package substrate **210** may be, for example, a PCB. The first package substrate **210** may include a base layer **211**, a solder resist layer **212**, an upper pad **213**, a lower pad **214**, and a protruding unit **215**. The solder resist layer **212** may cover an upper surface and a lower surface of the base layer **211**. The upper pad **213** may be positioned above the upper surface of the base layer **211** and may not be covered by the solder resist layer **212**. The lower pad **214** may be positioned on the lower surface of the base layer **211** and may not be covered by the solder resist layer **212**. The upper pad **213** and the lower pad **214** may be connected to each other through an interconnection (not shown) in the base layer **211**. The protruding unit **215** may extend from the base layer **211** to a lower surface of the first shielding wall **240**. That is, one end of the protruding unit **215** may be in contact with the base layer **211** and the other end thereof may be in contact with the lower surface of the first shielding wall **240**. The protruding unit **215** may be positioned adjacent to an edge of the first package substrate **210**.

The first semiconductor chip **220** may be a logic chip or a memory chip. The first semiconductor chip **220** may be attached to an upper surface of the first package substrate **210** by a chip adhesive layer **223**. The first semiconductor chip **220** may be connected to the first package substrate **210** by a bonding wire **221**. In another example, the first semiconductor chip **220** is connected to the first package substrate **210** by a bump. Also, the first semiconductor chip **220** is spaced apart from the first shielding wall **240** and the first shielding cover **250**.

The first molding unit **230** may cover an upper surface of the first package substrate **210** and surround the first semiconductor chip **220**.

The first shielding wall **240** may extend around sides of the first molding unit **230**. One end of the first shielding wall **240** may be in contact with the protruding unit **215** of the first package substrate **210** and another end of the first shielding wall **240** may be in contact with the first shielding cover **250**.

In some examples, the first shielding wall **240** is attached to the first package substrate **210** by a first shielding wall



adhesive layer **260**. The first shielding wall adhesive layer **260** may be positioned between the solder resist layer **212** of the first package substrate **210** and the lower surface of the first shielding wall **240**. The protruding unit **215** of the first package substrate **210** may extend through the first shielding wall adhesive layer **260**.

The first shielding cover **250** may cover an upper surface of the first molding unit **230** and be in contact with the first shielding wall **240**.

The second sub-package SP2 may include a second package substrate **310**, a second semiconductor chip **320**, a second molding unit **330**, and an external connecting unit **370**.

The second package substrate **310** may be, for example, a PCB. The second package substrate **310** may include a base layer **311**, a solder resist layer **312**, an upper pad **313**, and a lower pad **314**. The solder resist layer **312** may cover an upper surface and a lower surface of the base layer **311**. The upper pad **313** may be positioned above the upper surface of the base layer **311** and may not be covered by the solder resist layer **312**. The lower pad **314** may be positioned on the lower surface of the base layer **311** and may not be covered by the solder resist layer **312**. The upper pad **313** and the lower pad **314** may be connected to each other through an interconnection (not shown) in the base layer **211**.

The second semiconductor chip **320** may be a logic chip or a memory chip. The second semiconductor chip **320** may be attached to an upper surface of the second package substrate **310** by a chip adhesive layer **323**. The second semiconductor chip **320** may be connected to the second package substrate **310** by a bonding wire **321**. In other examples, the second semiconductor chip **320** is connected to the second package substrate **310** by a bump.

The second molding unit **330** may cover at least a portion of the upper surface of the second package substrate **310** and surround the second semiconductor chip **320**.

The external connecting unit **370** may be arranged on the lower surface of the second package substrate **310**.

The inter-package connecting unit **270** may be arranged between the first sub-package SP1 and the second sub-package SP2. In particular, the inter-package connecting unit **270** may be arranged between the first package substrate **210** of the first sub-package SP1 and the second package substrate **310** of the second sub-package SP2. The inter-package connecting unit **270** may connect the first sub-package SP1 and the second sub-package SP2. The inter-package connecting unit **270** may comprise, for example, gold (Au), copper (Cu), nickel (Ni), tin (Sn), and lead (Pb), or a combination thereof. The inter-package connecting unit **270** may include, for example, a solder ball.

FIG. **6** is a cross-sectional view of another example of a semiconductor package **200a** according to the inventive concept. Hereinafter, mainly only the differences between the semiconductor package **200** shown in FIG. **5** and the semiconductor package **200a** shown in FIG. **6** will be described.

Referring to FIG. **6**, the second sub-package SP2 may further include a second shielding wall **340** and a second shielding cover **350**.

The second shielding wall **340** may extend circumferentially around (surround sides of) the second molding unit **330**. A plurality of the inter-package connecting units **270** may be arranged around the second shielding wall **340**. One end of the second shielding wall **340** may be in contact with a protruding unit **315** of the second package substrate **310**

and the other end of the second shielding wall **340** may be in contact with the second shielding cover **350**.

In some examples, the second shielding wall **340** is attached to the second package substrate **310** by a second shielding wall adhesive layer **360**. The second shielding wall adhesive layer **360** may be positioned between the solder resist layer **312** of the second package substrate **310** and the second shielding wall **340**. The protruding unit **315** of the second package substrate **310** may extend through the second shielding wall adhesive layer **360**.

The second shielding cover **350** may cover an upper surface of the second molding unit **330** and be in contact with the second shielding wall **340**.

FIG. **7** is a cross-sectional view of still another example of a semiconductor package **200b** according to the inventive concept. Hereinafter, mainly only the differences between the semiconductor package **200** of FIG. **5** and the semiconductor package **200b** of FIG. **7** will be described.

Referring to FIG. **7**, a first shielding wall **240a** may have at least one opening **2400P** extending radially therethrough. The opening **2400P** may be a hole or a slit. The dimensions of the opening **2400P** are so small that the first shielding wall **240a** is still able to effect an electromagnetic shielding of the at least one chip **220**. When a space surrounded by the shielding wall **240a** is filled with molding material to form the molding unit **230**, the opening **2400P** allows excess molding material to pass through the shielding wall **240a**.

FIGS. **8A** to **8D** are illustrate an example of a method of fabricating a semiconductor package according to the inventive concept. In this figures, elements of the package previously described with reference to FIGS. **1-3** will be denoted by like reference numerals.

Referring to FIG. **8A**, package substrate **110** is provided. The package substrate **110** includes at least one base layer (or simply "base") **111**, solder resist layer **112** covering the upper surface and the lower surface of the base layer **111**, upper pads **113** above the upper surface of the base layer **111**, lower pads **114** on the lower surface of the base layer **111**, and a protruding unit **115** protruding through the solder resist layer **112** from the upper surface of the package substrate **110**.

External connecting unit **170** may be formed by forming electrically conductive terminals on the lower surface of the package substrate **110**. For example, the external connecting unit **170** may be formed by attaching solder balls on the lower surface of the package substrate **110**.

In addition, at least one semiconductor chip **120**, e.g., first semiconductor chip **120a** and the plurality of second semiconductor chips **120b**, is/are attached within a chip mounting region to an upper surface of the package substrate **110** by chip adhesive layer **123**. In the illustrated example, a lateral array of single and/or stacked chips is mounted to the package substrate **110** within respective chip mounting regions above the package substrate **110**.

Referring to FIG. **8B**, the shielding wall **140** is formed on the package substrate **110**. The shielding wall **140** may be attached to the upper surface of the package substrate **110** by shielding wall adhesive layer **160**. For example, the shielding wall adhesive layer **160** may be formed on the package substrate **110**, the shielding wall **140** may be placed over the shielding wall adhesive layer **160** and the shielding wall **140** may be pressed toward with the package substrate **110** by applying a force to the shielding wall **140**.

In some examples, the shielding wall **140** is pressed into contact with the protruding unit **115** of the package substrate **110**. In this case, the shielding wall adhesive layer **160** may be formed so as to cover the protruding unit **115**. After

placing the shielding wall **140** above the shielding wall adhesive layer **160**, a force may be applied to the shielding wall **140** such that the protruding unit **115** of the package substrate **110** is forced through the shielding wall adhesive layer **160** and into contact with the shielding wall **140**.

Referring to FIG. **8C**, the molding unit **130** is formed in spaces (the chip mounting regions) delimited by the shielding wall **140** and the package substrate **110**. First, mold material, i.e., a molding compound, is deposited on the upper surface of the package substrate **110** in the spaces delimited by the shielding wall **140**. Then, the mold material is cured, e.g., exposed to UV light, or allowed to cure. Hence, molded bodies, i.e., bodies of material molded by the shielding wall **140**, package substrate **110**, etc., are formed in the spaces (the chip mounting regions), respectively.

Referring to FIG. **8D**, the shielding wall **140** and the package substrate **110** may be cut to separate the package substrate **110** and shielding wall **140** between the semiconductor chip stacks, thereby producing a plurality of discrete units of the semiconductor packages.

Referring to FIG. **1**, shielding cover **150** may be formed above the molding unit **130**. The shielding cover **150** may be formed by, for example, attaching an electromagnetic absorbing tape to the top surface of the molding unit **130**. Alternatively, the shielding cover **150** may be formed by spraying electromagnetic absorbing (shielding) material onto the top of the molding unit **130**. In either case, the shielding cover **150** may also be attached to and cover the upper end of the shielding wall **140**.

In a fabrication method according to the inventive concept as described above, the shielding wall **140** and the shielding cover **150** may be formed easily, quickly and inexpensively.

FIG. **9** illustrates a stage in an example of a method of fabricating a semiconductor package, of the type shown in and described with reference to FIG. **4**, according to the inventive concept. The other stages of the method are similar to those shown in and described with reference to FIGS. **8A-8D**.

Referring to FIGS. **4** and **9**, the shielding wall **140a** has at least one opening **1400P**. Excess molding material, namely, molding material that has filled the space delimited by the shielding wall **140a** when the molding unit **130** is being formed, may pass into and even through outer ones the openings **1400P** in the shielding wall **140a** if excess molding material is forced by the molding process into the space. Therefore, the molding unit **130** may be formed easily and without damaging the components in and delimiting the space.

FIG. **10** illustrates a stage in an example of a method of fabricating a semiconductor package of the type shown in and described with reference to FIG. **5**, according to the inventive concept.

Referring to FIG. **10**, the first sub-package **SP1** is prepared. The first sub-package **SP1** may be prepared in a method similar to that shown in and described with reference to FIGS. **8A** to **8D**.

First, the first package substrate **210** is provided. The first package substrate **210** includes the base layer **211**, the solder resist layer **212** covering the upper surface and the lower surface of the base layer **211**, the upper pad **213** above the upper surface of the base layer **211**, the lower pad **214** on the lower surface of the base layer **211**, and the protruding unit **215** protruding through the solder resist layer **212**.

The inter-package connecting unit **270** is formed on a lower surface of the first package substrate **210**. For example, the inter-package connecting unit **270** may be formed by attaching solder balls to the lower surface of the

first package substrate **210**. In addition, the first semiconductor chip **220** is attached to an upper surface of the first package substrate **210** by the chip adhesive layer **223**.

Next, the first shielding wall **240** is attached to the first package substrate **210**. The first shielding wall **240** may be attached to the first package substrate **210** by the first shielding wall adhesive layer **260**.

Then, the first molding unit **230** is formed in a space surrounded by the first shielding wall **240**.

Next, the first shielding wall **240** and the first package substrate **210** may be cut.

Then, the first shielding cover **250** may be formed atop the first molding unit **230**. The first shielding cover **250** may be formed by, for example, attaching an electromagnetic radiation absorbing tape to the top surface of the first molding unit **230** (and to an upper end of the first shielding wall **240**). Alternatively, the first shielding cover **250** may be formed by spraying the top surface of the first molding unit **230** (and upper end of the first shielding wall **240**) with an electromagnetic radiation absorbing (shielding) material.

Meanwhile, the second sub-package **SP2** is prepared. First, the second package substrate **310** is provided. The second package substrate **310** includes the base layer **311**, the solder resist layer **312** covering the upper surface and the lower surface of the base layer **311**, the upper pads **313** on the upper surface of the base layer **311**, the lower pads **314** on the lower surface of the base layer **311**, and the protruding unit **315** extending through the solder resist layer **312**.

The external connecting unit **370** is formed on a lower surface of the second package substrate **310**. For example, the external connecting unit **370** may be formed by attaching solder balls to the lower surface of the second package substrate **310**. In addition, the second semiconductor chip **320** is attached to an upper surface of the second package substrate **310** by the chip adhesive layer **323**. Next, the second molding unit **330** extending circumferentially around the second semiconductor chip **320** is formed.

Then, the first sub-package **SP1** is to the second sub-package **SP2**. Thus, the semiconductor package **200** shown in FIG. **5** may be fabricated.

Furthermore, the preparing of the second sub-package **SP2** may also include attaching the second shielding wall **340** to the package substrate, forming molding unit **330** in the space delimited by the second shielding wall **340** and package substrate **3100**, and attaching the second shielding cover **350** to the top surface of the molding unit **330** and upper end surface of the second shielding wall **340**. In this case, the semiconductor package **200a** shown in FIG. **6** may be fabricated.

Finally, examples of the inventive concept have been described above in detail. The inventive concept may, however, be put into practice in many different ways and should not be construed as being limited to the examples described above. Rather, these examples were described so that this disclosure is thorough and complete, and fully conveys the inventive concept to those skilled in the art. Thus, the true spirit and scope of the inventive concept is not limited by the examples described above but by construing the following claims.

What is claimed is:

1. A semiconductor package comprising:
  - a package substrate;
  - at least one semiconductor chip on an upper surface of the package substrate;
  - a conductive wall that extends around sides of the at least one semiconductor chip above the package substrate;

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a molded body in a space delimited by the conductive wall and the package substrate;

a shielding cover that covers the molded body and the conductive wall; and

an adhesive between the conductive wall and the package substrate,

wherein the package substrate comprises a protrusion that protrudes from the upper surface of the package substrate, and

the adhesive is in contact with the protrusion and the conductive wall.

2. The semiconductor package of claim 1, wherein a thickness of the conductive wall in a direction parallel to the upper surface of the package substrate is greater than a thickness of the shielding cover in a direction perpendicular to the upper surface of the package substrate.

3. The semiconductor package of claim 1, wherein the conductive wall is spaced apart from the at least one semiconductor chip.

4. The semiconductor package of claim 1, wherein the shielding cover is spaced apart from the at least one semiconductor chip.

5. The semiconductor package of claim 1, wherein the protrusion extends through the conductive wall.

6. The semiconductor package of claim 1, wherein the protrusion is in contact with the conductive wall.

7. The semiconductor package of claim 1, wherein the adhesive surrounds the protrusion.

8. The semiconductor package of claim 1, wherein the protrusion is grounded.

9. The semiconductor package of claim 1, wherein the conductive wall is grounded through the protrusion.

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10. The semiconductor package of claim 1, wherein the shielding cover is grounded through the conductive wall and the protrusion of the package substrate.

11. The semiconductor package of claim 1, wherein the protrusion is contiguous along a closed loop as viewed in a plan view of the semiconductor package.

12. The semiconductor package of claim 1, wherein the protrusion comprises a plurality of portions spaced apart from one another along a path of a closed loop as viewed in a plan view of the semiconductor package.

13. The semiconductor package of claim 1, wherein the protrusion comprises a plurality of portions spaced apart from one another and each disposed adjacent to a respective one of sides of the package substrate.

14. The semiconductor package of claim 13, wherein the package substrate has four sides and the protrusion consists of four portions adjacent to the four sides of the package substrate, respectively.

15. A semiconductor package comprising:

a package substrate comprising a protrusion that protrudes from an upper surface of the package substrate;

at least one semiconductor chip on an upper surface of the package substrate;

a conductive wall that extends around sides of the at least one semiconductor chip above the protrusion;

a molded body in a space delimited by the conductive wall and the package substrate;

a shielding cover that covers the molded body and the conductive wall; and

an adhesive between the conductive wall and the package substrate,

wherein the adhesive surrounds the protrusion.

\* \* \* \* \*